

RP-50 Polyimide

RP-50 is a new, high-temperature polyimide coating system that possesses excellent dielectric properties.

RP-50 Characteristics:

- High heat resistance (-150°F to +575°F)
- High Tg (+541°F or 283°C)
- Excellent dielectric properties
- Low moisture absorption
- Excellent adhesion to metal substrates
- Adhesion to Kapton, Nomex®, and many other engineered polymers
- Resistant to microcracking
- Resistant to chemical corrosion



RP-50 Applications:

High -temperature coating system for:

- Insulating electrical wire
- Electrical motor varnish
- Protecting Kapton circuits
- High-strength dielectric coating for harsh and corrosive environments
- Bonding interface for polyimide foams

RP-50 was developed and patented by NASA Langley Research Center to solve performance problems in extreme heat, chemical, and corrosive environments without microcracking or blistering. **RP-50** is now commercially available worldwide due to a successful technology transfer between NASA and **Unitech, Inc.** of Hampton, Virginia, USA.

Solvent and Moisture Absorption

Solvent and moisture absorption of RP50 Film (Exposed 7 days at room temperature)

Fluid	% Absorption (% weight gain)
Jet fuel	0.00%
Lubricating oil	0.00%
Hydraulic fluid	0.00%
Alkaline cleaning solution	0.50%
Water	0.00%
Seawater	0.00%

Test Data

Fracture toughness (G_{IC})	1050 J/m ² (compared with epoxy 32 J/m ²)
Adhesion (ASTM D3359, Tape test)	Aluminum- 5B (100%) Cold-Rolled Steel- 5B (100%)
Impact (ASTM D2794, Resistance of organic coatings to the effects of Rapid Deformation)	Pass 160 in/lb direct Pass 160 in/lb reverse impact
Flexibility (ASTM D522, Mandrel bend test of organic coatings)	Pass 1/4"
Dielectric constant	2.9 at 10GHz
Dielectric strength	RP50 at 4.0 mil film thickness will hold 3,300 volts

Cure Cycle

A typical cure cycle for RP50 film:

10 minutes @ 125°C, raise temperature to 175°C and hold for 10 minutes, raise temperature to 225°C and hold for 10 minutes, raise temperature to 275°C and hold for 10 minutes, raise temperature to 325°C and hold for 20 minutes.

*Cure times may vary due to total film thickness applied